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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/017,521	12/14/2001	Nayef M. Abu-Ageel	CORE-73	8234
75	90 02/05/2004		EXAMINER	
Pandiscio & Pandiscio			LEE, JOHN D	
470 Totten Pone Waltham, MA			ART UNIT PAPER NUMBER 2874	
,				
			DATE MAILED: 02/05/2004	

Please find below and/or attached an Office communication concerning this application or proceeding.

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	Application No.	Applicant(s)	-			
	10/017,521	ABU-AGEEL, NAY	/EF M.			
Office Action Summary	Examiner	Art Unit				
	John D. Lee	2874				
The MAILING DATE of this communication app Period for Reply	pears on the cover sheet with the	correspondence ad	dress			
A SHORTENED STATUTORY PERIOD FOR REPL THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.1 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a repl - If NO period for reply is specified above, the maximum statutory period of - Failure to reply within the set or extended period for reply with, by statute Any reply received by the Office later than three months after the mailine earned patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a reply be till y within the statutory minimum of thirty (30) day will apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONE	mely filed ys will be considered timely the mailing date of this co ED (35 U.S.C. § 133).				
Status						
1) Responsive to communication(s) filed on	<u>_</u> .					
2a) ☐ This action is FINAL . 2b) ☑ This	s action is non-final.					
,	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.					
Disposition of Claims						
4) ⊠ Claim(s) 1-34 is/are pending in the application 4a) Of the above claim(s) is/are withdra 5) □ Claim(s) is/are allowed. 6) □ Claim(s) is/are rejected. 7) □ Claim(s) is/are objected to. 8) ⊠ Claim(s) 1-34 are subject to restriction and/or	wn from consideration.	·				
Application Papers						
9)☐ The specification is objected to by the Examiner.						
10)☐ The drawing(s) filed on is/are: a)☐ accepted or b)☐ objected to by the Examiner.						
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.						
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority document 2. Certified copies of the priority document 3. Copies of the certified copies of the priority application from the International Burea * See the attached detailed Office action for a list	is have been received. Is have been received in Applicat Inity documents have been receiv In (PCT Rule 17.2(a)).	ion No ed in this National ed.	Stage			
Attachment(s)						
1) Notice of References Cited (PTO-892) 4) Interview Summary (PTO-413)						
Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date	Paper No(s)/Mail D	ate)-152) -			

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Restriction to one of the following inventions is required under 35 U.S.C. § 121:

I. Claims 1-17, 33, and 34, drawn to a reflective optical switch/attenuator

and a method of directing light paths therewith, classified in class 385,

subclass 18.

II. Claims 18-32, drawn to a method of fabricating an optical

switch/attenuator involving SOI wafer patterning followed by selective

etching, classified in class 216, subclass 24.

The inventions are distinct, each from the other because:

Inventions II and I are related as process of making and product made. The

inventions are distinct if either or both of the following can be shown: (1) that the

process as claimed can be used to make other and materially different products or (2)

that the product as claimed can be made by another and materially different process

(MPEP § 806.05(f)). In the instant case the product as claimed (and its corresponding

use) can be made by another and materially different process such as a laser-based

cutting/trimming process.

Because these inventions are distinct for the reasons given above and have

acquired a separate status in the art as shown by their different classification, restriction

for examination purposes as indicated is proper.

Applicant is advised that the reply to this requirement to be complete must

include an election of the invention to be examined even though the requirement may

be traversed (37 CFR § 1.143).

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Any inquiry concerning the merits of this communication should be directed to Examiner John D. Lee at telephone number (571) 272-2351. The Examiner's normal work schedule is Tuesday through Friday, 6:30 AM to 5:00 PM. Any inquiry of a general or clerical nature (i.e. a request for a missing form or paper, etc.) should be directed to the Technology Center 2800 receptionist at telephone number (703) 308-0956, to the technical support staff supervisor (Team 2) at telephone number (571) 272-1615, or to the Technology Center 2800 Customer Service Office at telephone number (571) 272-1626.

John D. Lee Primary Patent Examiner Group Art Unit 2874